



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application Serial No. .... 10/643,680  
Filing Date ..... August 18, 2003  
Inventor ..... Brenda D. Kraus et al.  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 1762  
Examiner ..... Brian K. Talbot  
Attorney's Docket No. .... MI22-2310  
Customer No. .... 021567  
Title: Atomic Layer Deposition Methods of Forming Conductive Metal Nitride  
Comprising Layers

**RESPONSE TO AUGUST 14, 2007 OFFICE ACTION**

To: Mail Stop Amendment  
Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

From: Mark Matkin (Tel. 509-624-4276; Fax 509-838-3424)  
Wells St. John P.S.  
601 West First Avenue, Suite 1300  
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Responsive to the Office Action dated August 14, 2007, Applicant  
amends and remarks as follows:

**AMENDMENTS**